

Erratum

Erratum to “The preparation and thermoelectric properties of molten salt electrodeposited boron wafers”
[J. Solid State Chem. 177 (2004) 537–541]

Y. Kumashiro^{a,*}, S. Ozaki^a, K. Sato^a, Y. Kataoka^a, K. Hirata^a, T. Yokoyama^a,
S. Nagatani^b, K. Kajiyama^b

^aGraduate School of Engineering, Yokohama National University, 79-5 Tokiwadai, Hodogaya-ku, Yokohama 240-8501, Japan

^bMAC Science Company Ltd., 5289 Nagatsuda-cho, Midori-ku, Yokohama 226-0026, Japan

The inset to Fig. 3 contains some incorrect characters. The correct Fig. 3 is shown here.

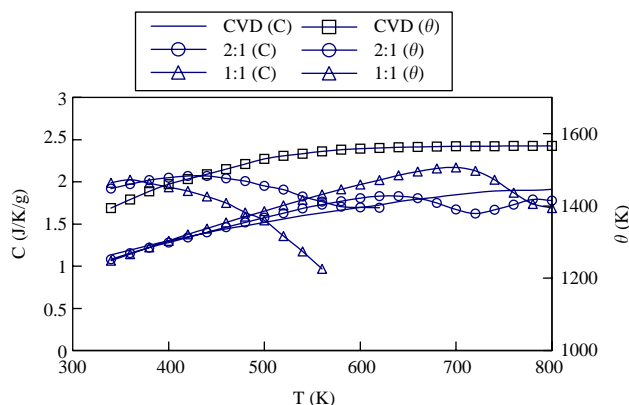


Fig. 3. Temperature dependence of heat capacity and Debye temperature. (The results of amorphous CVD wafer [3] are also shown.)

DOI of original article: 10.1016/j.jssc.2003.05.004

*Corresponding author. Fax: +81 45 339 3949.

E-mail address: kumashiro@ynu.ac.jp (Y. Kumashiro).